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APPLICATION NO.	FIL	JING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO	
10/813,446	03/31/2004		Noboru Noda	016887-1104	3787	
22428	7590	12/30/2005		EXAM	EXAMINER	
FOLEY AN SUITE 500	D LARD	NER LLP	CRANE, SARA W			
3000 K STREET NW				ART UNIT	PAPER NUMBER	
WASHINGT	ON, DC	20007	2811			

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
	10/813,446	NODA, NOBORU				
Office Action Summary	Examiner	Art Unit				
	Sara W. Crane	2811				
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence address				
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tirr vill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	lely filed the mailing date of this communication. D (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on 17 Oc	<u>ctober 2005</u> .					
<u>'</u>	This action is FINAL . 2b)⊠ This action is non-final.					
. —	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
closed in accordance with the practice under E	х рапе Quayle, 1935 С.D. 11, 45	3 O.G. 213.				
Disposition of Claims						
 4) Claim(s) 1-19 is/are pending in the application. 4a) Of the above claim(s) 7-18 is/are withdrawn 5) Claim(s) is/are allowed. 6) Claim(s) 1,3,5 and 6 is/are rejected. 7) Claim(s) 2,4 and 19 is/are objected to. 8) Claim(s) are subject to restriction and/or 	from consideration.					
Application Papers						
9) The specification is objected to by the Examiner 10) The drawing(s) filed on is/are: a) access Applicant may not request that any objection to the of Replacement drawing sheet(s) including the correction of the original of the correction of the original of the original of the correction of the original of the original of the original	epted or b) objected to by the formula of the following of the held in abeyance. See the formula of the drawing	e 37 CFR 1.85(a). ected to. See 37 CFR 1.121(d).				
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) □ All b) □ Some * c) □ None of: 1. □ Certified copies of the priority documents have been received. 2. □ Certified copies of the priority documents have been received in Application No 3. □ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received.						
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:					

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Art Unit: 2811

DETAILED ACTION

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1, 3, 5, and 6 are rejected under 35 U.S.C. 103(a) as being unpatentable over Miwa, 6,043,552.

With respect to claim 1, figure 1 of Miwa shows a semiconductor device having n-type collector 3, and a p-type graft base (shown as an outdiffusion from p+ polysilicon 9 (column 6, lines 25-34). The emitter is shown at 11, and the base is understood to be the part of layer 10 that is between the collector and the emitter. The "base layer" of claim 1 is therefore identified as the part of layer 10 that is formed on the collector layer 3. The base is contacted by layer 9, and by the parts of layer 10 that lie on top of and on the inner side surface of layer 9. Layer 9 is therefore identified as a "first base leading--out region," with the leading-out function inherent, or alternatively, obvious, because the layer extends from the base itself to a point under to base contact 17. Similarly, the parts of layer 10 that are formed on the upper surface and the side surface of layer 9 are identified as a "second base leading-out region," with the leading-out function also inherent or, alternatively, obvious. Layer 16 is identified as "an emitter leading-out region" for the same reasons.

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With respect to claim 3, polysilicon layer 9 and overlying SiGe layer 10 are both made of silicon. With respect to claim 5, layer 10 is epitaxial (column 4, line 57). With respect to claim 6, layer 10 is SiGe (column 4, lines 64-65).

Claims 2, 4, and 19 would be allowable if expressed in completed form.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to S. Crane, whose telephone number is (571) 272-1652.

The supervisor for Art Unit 2811, Eddie Lee can be reached on (571) 272-1732. The fax phone number for the organization where this application or proceeding is assigned is (571) 273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Sara W. Crane Primary Examiner

Art Unit 2811